AMENDMENT TO THE CLAIMS

1. (original): A method for automated focusing of an electron image, the method comprising:

determining an energy filter cut-off voltage; and adjusting a focusing condition in compensation for a change in the energy-filter cut-off voltage.

- 2. (original): The method of claim 1, further comprising:
 varying an energy filter voltage to different levels;
 measuring an intensity of detected electrons at each of the different levels; and
 analyzing the intensity data so as to determine the energy filter cut-off voltage.
- 3. (original): The method of claim 1, wherein the focusing condition comprises a wafer bias voltage, and wherein the wafer bias voltage is varied in correspondence to the change in the energy filter cut-off voltage.
- 4. (original): The method of claim 1, wherein the focusing condition comprises an objective lens focusing strength.
- 5. (original): The method of claim 1, wherein the focusing condition comprises an extraction field strength.
- 6. (original): The method of claim 1, wherein the focusing condition comprises a source voltage level.
- 7. (original): The method of claim 1, further comprising using a contrast-based focusing procedure for fine focusing of the electron image.
- 8. (cancelled):
- 9. (cancelled):

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- 10. (cancelled):
- 11. (original): A electron beam inspection apparatus, the apparatus including an autofocusing means that comprises:

means for determining an energy filter cut-off voltage; and means for adjusting a focusing condition in compensation for a change in the energy-filter cut-off voltage.

- 12. (cancelled)
- 13. (cancelled)
- 14. (cancelled)
- 15. (cancelled)
- 16. (cancelled)
- 17. (cancelled)
- 18. (cancelled):
- 19. (cancelled):
- 20. (cancelled):
- 21. (cancelled):
- 22. (cancelled)
- 23. (cancelled):